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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO	
10/600,763	06/23/2003	Norio Ohkuma	03560.003317.	5711	
5514	7590 10/15/2004		EXAMINER		
FITZPATRICK CELLA HARPER & SCINTO 30 ROCKEFELLER PLAZA			CULBERT, F	CULBERT, ROBERTS P	
	, NY 10112		ART UNIT	PAPER NUMBER	
			1763		
	,		DATE MAILED: 10/15/2004	DATE MAILED: 10/15/2004	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
Office Action Comme	10/600,763	OHKUMA, NORIO				
Office Action Summary	Examiner	Art Unit				
	Roberts Culbert	1763				
The MAILING DATE of this communication ap Period for Reply	pears on the cover sheet with t	he correspondence address				
A SHORTENED STATUTORY PERIOD FOR REPL THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1. after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a rep. If NO period for reply is specified above, the maximum statutory period.  - Failure to reply within the set or extended period for reply will, by statut Any reply received by the Office later than three months after the mailir earned patent term adjustment. See 37 CFR 1.704(b).	136(a). In no event, however, may a reply to a reply to a reply to a reply to a reply within the statutory minimum of thirty (30 will apply and will expire SIX (6) MONTHS a cause the application to become ARAND.	be timely filed ) days will be considered timely. from the mailing date of this communication. ONED (35.U.S.C. 8.432)				
Status		•				
1) Responsive to communication(s) filed on 16 E	December 2003					
· · —						
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is						
closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.						
Disposition of Claims						
4)⊠ Claim(s) <u>1-8</u> is/are pending in the application.						
4a) Of the above claim(s) <u>8</u> is/are withdrawn from consideration.						
5) Claim(s) is/are allowed.						
6)⊠ Claim(s) 1-7 is/are rejected.						
7) Claim(s) is/are objected to.						
8) Claim(s) are subject to restriction and/o	or election requirement.					
Application Papers						
9)☐ The specification is objected to by the Examine	ar.					
10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).						
11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.						
Priority under 35 U.S.C. § 119	*					
12) △ Acknowledgment is made of a claim for foreign  a) △ All b) ☐ Some * c) ☐ None of:  1. △ Certified copies of the priority documents  2. ☐ Certified copies of the priority documents  3. ☐ Copies of the certified copies of the prior application from the International Bureau	s have been received. s have been received in Applicatives and the comments have been rece	ation No				
* See the attached detailed Office action for a list		ned.				
	or and doranica copies not recei	veu.				
	,					
Attachment(s)						
1) Notice of References Cited (PTO-892)  4) Interview Summary (PTO-413)						
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)  3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)  Paper No(s)/Mail Date.  5) Notice of Informal Patent Application (PTO-152)						
Paper No(s)/Mail Date 9/23/03, 12/16/03.	6) Other:	FF				

### **DETAILED ACTION**

## Election/Restrictions

Restriction to one of the following inventions is required under 35 U.S.C. 121:

- I. Claims 1-7, drawn to an etching method, classified in class 216, subclass 27.
- II. Claim 8, drawn to an ink-jet printhead, classified in class 347, subclass 20.

The inventions are distinct, each from the other because of the following reasons:

Inventions II and I are related as process of making and product made. The inventions are distinct if either or both of the following can be shown: (1) that the process as claimed can be used to make other and materially different product or (2) that the product as claimed can be made by another and materially different process (MPEP § 806.05(f)). In the instant case the process as claimed can be used to make other and materially different product such as a shadow mask.

Because these inventions are distinct for the reasons given above and have acquired a separate status in the art as shown by their different classification and recognized divergent subject matter, and the search required for Group I is not required for Group II, restriction for examination purposes as indicated is proper.

During a telephone conversation with Douglas Pinsky on 9/27/04 a provisional election was made without traverse to prosecute the invention of Group I, claims 1-7. Affirmation of this election must be made by applicant in replying to this Office action. Claim 8 is withdrawn from further consideration by the examiner, 37 CFR 1.142(b), as being drawn to a non-elected invention.

## Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

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Claims 1-6 are rejected under 35 U.S.C. 102(b) as being anticipated by U.S. Patent 5,141,596 to Hawkins et al.

Referring to Figures 7-9, Hawkins et al. teaches a method for making a through-hole in a silicon substrate comprising the steps of: forming a high-impurity-concentration region (30) in the periphery of a through-hole-forming region at a first surface of the silicon substrate (32); forming an etching stop layer (36) over the through-hole-forming region and the high-impurity-concentration region; forming a mask layer (36) having an opening on a second surface of the silicon substrate, the second surface being opposite to the first surface; etching the silicon substrate at the opening through the mask layer until the etching stop layer is exposed to the second surface; (Figure 9 and Col. 7, Lines 38-48) further etching the silicon substrate until the etched portion extends to the high-impurity-concentration region; (Figure 9 and Col. 7, Lines 38-48) and removing the etching stop layer at least at the portion exposed to the second surface. (Col. 7, Lines 49-50)

Regarding Claims 2-4, Hawkins et al. teaches the high-impurity-concentration region is doped with boron impurity concentration of 10<sup>20</sup>/cm<sup>3</sup> (Col. 6, Lines 62-64)

Regarding Claim 5, Hawkins et al. teaches the high-impurity-concentration region has a width of 1 to 20  $\mu$ m and a depth of 1 to 3  $\mu$ m. (Col. 6, Lines 40-65)

Regarding Claim 6, Hawkins et al. teaches the high-impurity-concentration region is formed by forming an impurity diffusion layer in the first surface of the silicon substrate.

## Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claim 7 is rejected under 35 U.S.C. 103(a) as being unpatentable over U.S. Patent 5,141,596 to Hawkins et al.

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Regarding Claim 7, Hawkins teaches the method of the invention substantially as claimed, but does not teach that the silicon nitride etch stop layer is formed using low-pressure vapor deposition. However, Official Notice is taken that it is notoriously old and well known in the art of forming silicon nitride films on silicon substrates to use low-pressure vapor deposition. It would have been obvious to one of ordinary skill in the art to use low-pressure vapor deposition to form the silicon nitride etch stop layer of Hawkins in order to benefit from, uniform coverage, low levels of particulate contamination, and reduced processing cost.

#### Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Roberts Culbert whose telephone number is (571) 272-1433. The examiner can normally be reached on Monday-Friday (7:30-4:00).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Gregory Mills can be reached on (571) 272-1439. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

R. Culbert A. Cullet

P. Hassanzadel primary Examiner AU 1763